



A QUANTUM LEAP IN PURIFICATION PERFORMANCE

The ASDPure[™] is a heated getter-based noble gas purifier. Get the most of your analytical instruments with the dual heated getter technology (Single vessel optional). Enhances the lifetime and purification performance.

UNIQUE FEATURES

- Improved performance and twice the lifetime of other purifiers on the market with dual vessels purification process
- No H₂ release with dual vessel design
- ASDPure $^{\text{TM}}$ purifies Ar, He, Ne, Xe and Kr (N_2 purification optional)
- Higher flow capacity: 300 mL/min nominal flow (1L/min optional)

APPLICATIONS

- Carrier gas purifier
- Zero gas generator for calibration of on-line analyzers
- Reference gas generator for TCD analyzers
- Mass spectrometer
- Perfect for all kinds of detector: plasma (Epd, PED), HID, DID, FID, PDID, TCD, ECD, etc.

ENHANCED BY



Leak detection capability

Better leak integrity

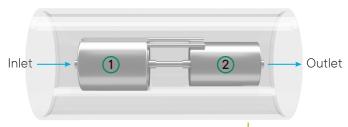
No dead volume

Compatible with the industrial standard double ferrule type

DUAL VESSEL PURIFICATION PROCESS

ASDPure is configured with a dual vessel purification process (Single vessel optional). The proprietary dual stage purification design unlocks a better purification process and higher performances.

- High temperature (400 °C) first stage to remove all the main impurities such as O₂, N₂, HCs, CO, CO₂, H₂O, VOCs
- \bigcirc Lower temperature (180 °C) second stage to remove H $_2$



Dual vessel purification process

All ASD products respect CE/RoHS (CSA optional) standards.

* = patent pending



SPECIFICATIONS

Gas purified	Ar, He, Ne, Xe, Kr (N ₂ optional)
Impurities removed	H ₂ O, O ₂ , CO, CO ₂ , H ₂ , THC, CH ₄ , N ₂
Impurity level achievable	< 5 ppb or < 1 ppb with dual vessel and LipLOK™/VCR™
Nominal flow	300 mL/min (1 L/min in option)
Fitting connections	ASD LipLOK [™] fitting, compatible with Swagelok [™] double ferrule type or VCR [™]
Supply voltage	115 VAC or 220 VAC, 50-60 Hz
Power consumption	20 watts
Weight	1,6 kg (3,53 lbs)
Dimensions (H x W x D)	300 x 82 x 82 mm (11,81 x 3,23 x 3,23 in)

AMERICA

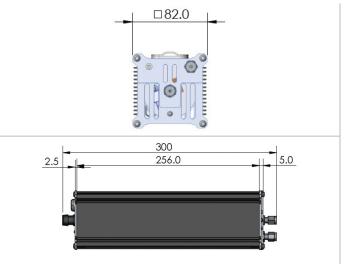
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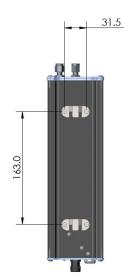
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ASIA





	VESSEL CONFIGURATION		OUTLET PURITY (ppb)*	
	NOMINAL FLOW (mL/min)	VESSEL TECHNOLOGY	SWAGELOK™	VCR TM / LipLOK TM
APURE-A-B-C-03-E-S-G	300	Single	< 10	< 5
APURE-A-B-C-03-E-D-G	300	Dual	< 10	< 1
APURE-A-B-C-10-E-D-G	1000	Dual	< 10	< 1

* Optimum outlet purity achieved with purifier outlet pressure above 50 PSIG

PRODUCT NOMENCLATURE Product part number: APURE-A-B-C-DD-E-F-G

with purifier outlet pressure	PARAMETER	OPTIONS	
above 50 PSIG ** Hydrogen impurity	А	1 2	115 VAC version 220 VAC version
	В	O 1 2	Double ferrule type fitting VCR™ type fitting LipLOK™
	С	O 1	½" fitting type ¼" fitting type
	DD	03 10	300 mL/min 1000 mL/min
	E	0 1 2 3 4	North american plug European plug UK plug Chinese plug Others (no plug or specified)
	F	S D	Single vessel Dual vessel
Information in this paper is subject to change without prior notice.	G	S N	Standard version (Ar, He, Xe, Ne, Kr) $\rm N_2$ version

All ASDevices products respect CE/RoHS (CSA optional) standards.

* = patent pending

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